Micro-Machined Micro-Optical Bench for Optoelectronic Packaging

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We report a novel scheme for optoelectronic packaging using surface micro-machining technique. *Free-space* micro-optical bench (MOB) enables a large optical system to be monolithically integrated on a small Si chip. Unlike the conventional silicon optical bench technology where waveguides are used to connect various optical devices [1], the MOB integrated active devices with vertical, three-dimensional micro-optical elements in free-space. Stationary and movable micro-optical components are fabricated on Si substrate using micro-machining technique. Pre-alignment of optics is realized by IC-like process: optical lithography. Additional fine alignment after assembly is achieved by the on-chip movable components. Three-dimensional micro-optics fabricated by surface-micromachining technique have been demonstrated [2-3] using micro-hinges and micro-spring latches [4], as shown on Fig. 1. Micro-Fresnel lenses standing on Si substrate with focal length of several hundred μ m's to a few millimeters have been demonstrated [2]. In this paper, we present a novel rotatable micro-mirror, and a three-dimensional self-alignment structure (400- μ m-tall) for integrating active optical components such as semiconductor lasers or isolators on MOB.

The rotatable micro-mirror is realized by fixing the hinges of folded micro-mirror to a rotatable plate instead of the silicon substrate. The rotatable plate itself is implemented by a suspended polysilicon layer whose center is fixed by a polysilicon hub [5]. The SEM photograph of the rotatable micro-mirror is shown in Fig. 2. The indicator on the lower part of the picture, originally pointing at 0° tick (indicated by the white arrow), has been rotated counter-clockwise by 20° (two ticks). We also introduced a new side-latch to precisely fix the angle of the vertical optical components and enhance their mechanical strength. The side-latch is implemented by a similar polysilicon plate folded in the orthogonal direction. The plate has a V-shape opening on the top edge to guide the mirror plate into a 2- μ m-wide groove in the center, as shown in Fig. 2.

In order to integrate the MOB with active optical devices such as semiconductor lasers, we have designed a set of novel self-alignment structures using the same folded polysilicon technology, as illustrated in Fig. 3(a). The edge-emitting laser is mounted on its side for accurate positioning of the active emitting spot. By precise scribing, the optical axis is placed at 254 μ m above the Si substrate. The wedge-shaped opening on the self-alignment plates gradually guides the active side of the laser towards the flat edge of the wedges. This unique design allows us to accommodate lasers with a large variation of thickness (from 100 μ m to 140 μ m thick). The height of the self-alignment structure permits more precise alignment. After assembly, the laser is electrically contacted by silver epoxy. Figure 3(b) is the SEM picture of a laser diode integrated with a micro-Fresnel lens.

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